

## The First X-Ray Structural Analysis and Photolysis of Gerमतetrasilacyclopentanes

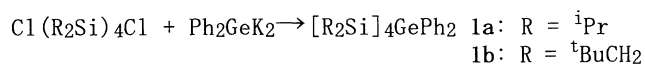
Hideo Suzuki, Nozomu Kenmotu, Ken Tanaka, Hamao Watanabe,\* and Midori Goto\*†  
 Department of Chemistry (Materials Science), Faculty of Engineering, Gunma University, Kiryu, Gunma 376  
 †National Institute of Materials and Chemical Research, Tsukuba, Ibaraki 305

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The five-membered ring system, gerमतetrasilacyclopentane,  $[\text{R}_2\text{Si}]_4\text{GePh}_2$  (1a:  $\text{R} = {}^i\text{Pr}$ ; 1b:  $\text{R} = {}^t\text{BuCH}_2$ ), was synthesized and characterized. Their structures have been determined by X-ray analysis, which showed the  $\text{Si}_4\text{Ge}$  rings of 1a and 1b to be an envelope and half-chair form, respectively. The photolyses of the compounds using a mercury lamp ( $\lambda = 254 \text{ nm}$ ) were carried out.

The chemistry of silacycles containing a heteroatom such as oxygen, nitrogen, etc. comprises intriguing subjects to be studied on their properties. Although a great number of studies of homosilacycles,  $\text{Si}_n$ , have been appeared so far, there are only limited reports on the ring systems containing a germanium,  $\text{Si}_n\text{Ge}$ .<sup>1</sup> We have previously studied some properties of a variety of peralkylated cyclopolysilanes,  $[\text{R}^1\text{R}^2\text{Si}]_n$  ( $n = 3 \sim 7$ )<sup>2</sup> and  $[\text{R}_2\text{Si}]_{30}$ .<sup>3</sup> Recently, we described the syntheses, structures and photochemical behaviors of four-membered  $\text{Si}_3\text{Ge}$  cycles,  $[\text{R}_2\text{Si}]_3\text{Ge}(\text{CH}_2\text{SiMe}_3)_2$  (A:  $\text{R} = {}^i\text{Pr}$ , B:  $\text{R} = {}^t\text{BuCH}_2$ ).<sup>1b</sup> We now should like to report on the syntheses, structures and photolyses of five-membered gerमतetrasilacyclopentanes,  $[\text{R}_2\text{Si}]_4\text{GePh}_2$  (1a:  $\text{R} = {}^i\text{Pr}$ , 1b:  $\text{R} = {}^t\text{BuCH}_2$ ).

Compounds 1a<sup>4</sup> and 1b<sup>5</sup> were obtained in good yields by the treatments of the corresponding 1,4-dichlorotetrasilanes with diphenylgermylene-dipotassium.<sup>6</sup>



The structures of 1a (Figure 1) and 1b<sup>7</sup> were determined by X-ray analysis.<sup>8,9</sup> The  $\text{Si}_4\text{Ge}$  rings of 1a and 1b were found to have envelope and half-chair forms, respectively. The Si-Si bond distances of the two are the same value, 2.414 Å, which is longer by ca. 0.024 Å than that, 2.390 Å (average), for the related 4-membered rings, A and B.<sup>1b</sup> Interestingly, as has been shown previously,<sup>2e</sup> this bond difference presumably corresponds to the bond elongation releasing steric repulsion between the bulky substituents in the 5-membered rings (1a; 1b) because of the same substituents ( ${}^i\text{Pr}$  or  ${}^t\text{BuCH}_2$ ) attached to the 4- (A; B) and 5-membered ring silicons (1a; 1b). The Si-Ge bond distances are 2.434 Å for 1a and 2.449 Å for 1b. The former is shorter than that (2.457 Å) for A, and the latter is nearly the same as that (2.444 Å) for B.<sup>1b</sup> The results observed in the 4- and 5-membered rings may reflect the different steric spaces and bond angles around these germaniums with each other, since the ring shape is generally due to the results of the

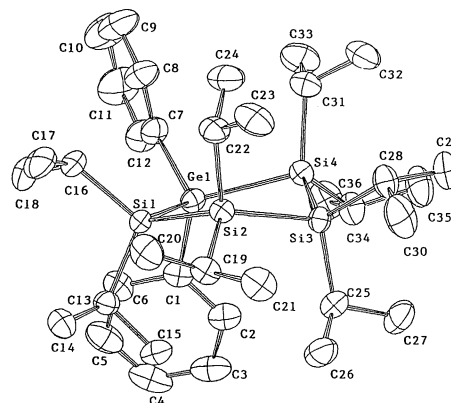


Figure 1. Molecular structure of 1a.

Selected bond distances (Å) and angles ( $^\circ$ ), and torsion angles: Ge(1)-Si(1) 2.436(1), Si(1)-Si(2) 2.399(1), Si(2)-Si(3) 2.427(1), Si(3)-Si(4) 2.417(1), Si(4)-Ge(1) 2.432(1); Si(1)-Ge(1)-Si(4) 110.5(1), Ge(1)-Si(1)-Si(2) 104.0(1), Si(1)-Si(2)-Si(3) 106.1(1), Si(2)-Si(3)-Si(4) 105.9(1), Si(3)-Si(4)-Ge(1) 100.9(1); Si(2)-Si(1)-Ge(1)-Si(4) -2.9(1), Si(1)-Si(2)-Si(3)-Si(4) 34.5(1), Ge(1)-Si(1)-Si(2)-Si(3) -18.8(1), Si(2)-Si(3)-Si(4)-Ge(1) -34.3(1), Si(3)-Si(4)-Ge(1)-Si(1) 23.1(1).

compromise between the steric repulsion between bulky substituents, ring strains and so on.

The ring-torsion angles (average) in the absolute value have been recognized to be a measure of the degree of planarity in cyclic molecules.<sup>10</sup> For 1a the value is 22.7 $^\circ$  and for 1b 32.3 $^\circ$ ; the former is the smallest in the related cyclopentasilanes ( $[\text{H}_2\text{Si}]_5$  26.7 or 27.9 $^\circ$ ,<sup>11</sup>  $[\text{Ph}_2\text{Si}]_5$  27.0 $^\circ$ ,<sup>12</sup>  $[(\text{CH}_2)_4\text{Si}]_5$  27.2 $^\circ$ ,<sup>13</sup>  $[(\text{CH}_2)_5\text{Si}]_5$  33.4 $^\circ$ <sup>13</sup>). The greater steric repulsions between bulkier neopentyl groups than isopropyls cause to produce larger torsion angles, forming the less planar ring of 1b than 1a. Thus, this fact has already been observed for the  $\text{Si}_3\text{Ge}$  rings of A and B (dihedral angles of 24.3 $^\circ$  for A and 35.6 $^\circ$  for B).<sup>1b</sup>

Generally, the photolysis of cyclopolysilanes and cyclopolygermanes is well-known to bring about ring contraction, giving the corresponding smaller rings with extrusion of silylene ( $\text{R}_2\text{Si}:$ ) and germylene ( $\text{R}_2\text{Ge}:$ ), respectively. Photolysis of 1a in cyclohexane ( $6.6 \times 10^{-3} \text{ mol dm}^{-3}$ ) for 1 h afforded  $[\text{Pr}_2\text{Si}]_4$  2a (17%),  $[\text{Pr}_2\text{Si}]_3\text{GePh}_2$  3a (9%),<sup>14</sup>  $\text{H}(\text{Pr}_2\text{Si})_3\text{H}$  (6.6%), and  $\text{H}(\text{Pr}_2\text{Si})_2\text{H}$  (5.7%), together with unreacted 1a (35%).<sup>15</sup> The formation of 2a and 3a from 1a suggests the extrusion of germylene ( $\text{Ph}_2\text{Ge}:$ ) and silylene ( ${}^i\text{Pr}_2\text{Si}:$ ), respectively. On irradiation for 1 h in the presence of excess

2,3-dimethylbutadiene (DMB, a trapping agent for silylenes and germylenes), 1a gave the trapping product of germylene, 1,1-diphenyl-3,4-dimethyl-1-germacyclopent-3-ene 4 (23%),<sup>16</sup> 2a (15%), 3a (6%) and unreacted 1a (31%).<sup>15</sup> Similarly, the photolysis of 1b in the presence of DMB in cyclohexane for 40 min gave the trapping product of germylene 4 (6.2%), trapping product of silylene, 1,1-dineopentyl-3,4-dimethyl-1-silacyclopent-3-ene (8.7%),<sup>1b</sup> [(<sup>t</sup>BuCH<sub>2</sub>)<sub>2</sub>Si]<sub>3</sub>GePh<sub>2</sub> 3b (7.8%),<sup>14</sup> and unreacted 1b (42%).<sup>15</sup> In the photolysate, many products containing [(<sup>t</sup>BuCH<sub>2</sub>)<sub>2</sub>Si]<sub>4</sub> 2b,<sup>17</sup> H((<sup>t</sup>BuCH<sub>2</sub>)<sub>2</sub>Si)<sub>2</sub>H, H((<sup>t</sup>BuCH<sub>2</sub>)<sub>2</sub>Si)<sub>2</sub>OH<sup>14</sup> and unidentified compounds in small amounts were detected by GC-MS analysis. As shown above, the formation of 3a and 3b, along with 2a and 2b, from 1a and 1b, respectively, is probably attributable to the presence of phenyl groups on germanium, the ring strain energies, and/or the steric repulsion between bulky substituents on ring silicons, while from the 4-membered rings, A and B, the ring contraction products accompanied by the extrusion of silylene could not be obtained.

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## References and Notes

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- 3 H. Watanabe, E. Tabei, M. Goto, and Y. Nagai, *J. Chem. Soc., Chem. Commun.*, **1987**, 522.
- 4 A solution of 1,4-dichlorooctaisopropyltetrasilane (0.33 g, 0.70 mmol) in benzene (1.4 ml) was slowly added to a red solution of diphenylgermylene-dipotassium (0.70 mmol) in a mixture of HMPA, THF and benzene. After 1 h stirring, the resulting mixture was worked up and recrystallized from ethanol to give colorless crystals of 1a (0.20 g, 41%), mp 370–378 °C (sealed capillary); <sup>13</sup>C NMR (δ, CDCl<sub>3</sub>) 16.12 (Si<sup>1,4</sup>CHMe<sub>2</sub>), 16.17 (Si<sup>2,3</sup>CHMe<sub>2</sub>), 21.72 and 23.13 (Si<sup>1,4</sup>CH(CH<sub>3</sub>)<sub>2</sub>), 23.65 and 23.83 (Si<sup>2,3</sup>CH(CH<sub>3</sub>)<sub>2</sub>), 127.09 (Ph-<sup>C</sup>), 127.88 (Ph-<sup>C</sup><sup>3,5</sup>), 136.24 (Ph-<sup>C</sup><sup>2,6</sup>), 141.53 (Ph-<sup>C</sup><sup>1</sup>); <sup>29</sup>Si NMR (δ, C<sub>6</sub>D<sub>6</sub>) -13.76 (Si<sup>2,3</sup>), -12.13 (Si<sup>1,4</sup>); UV (cyclohexane) λ<sub>max</sub> 280 nm (sh) (ε 5700 mol<sup>-1</sup>dm<sup>3</sup>cm<sup>-1</sup>); MS m/e (relative intensity) 684 (10, M<sup>+</sup>), 642 (8, [M-C<sub>3</sub>H<sub>6</sub>]<sup>+</sup>), 484 (50), 121 (100); Anal. Calcd for C<sub>36</sub>H<sub>66</sub>Si<sub>4</sub>Ge: C, 63.27; H, 9.73%. Found: C, 63.65; H, 10.04%.
- 5 Compound 1b was obtained by a treatment similar to 1a. 1b: 43% based on 1,4-dichlorotetrasilane used, mp 390–406 °C (sealed capillary); <sup>13</sup>C NMR (δ, CDCl<sub>3</sub>) 30.10 (Si<sup>2,3</sup>CH<sub>2</sub>Me<sub>3</sub>), 31.08 (Si<sup>1,4</sup>CH<sub>2</sub>-Bu<sup>t</sup>), 31.61 (Si<sup>1,4</sup>CH<sub>2</sub>Me<sub>3</sub>), 32.02 (Si<sup>2,3</sup>CH<sub>2</sub>-Bu<sup>t</sup>), 33.60 (Si<sup>1,4</sup>CH<sub>2</sub>C(CH<sub>3</sub>)<sub>3</sub>), 34.18 (Si<sup>2,3</sup>CH<sub>2</sub>-C(CH<sub>3</sub>)<sub>3</sub>), 127.39 (Ph-<sup>C</sup>), 127.49 (Ph-<sup>C</sup><sup>3,5</sup>), 137.57 (Ph-<sup>C</sup><sup>2,6</sup>), 142.13 (Ph-<sup>C</sup><sup>1</sup>); <sup>29</sup>Si NMR (δ, C<sub>6</sub>D<sub>6</sub>) -29.01 (Si<sup>2,3</sup>), -23.98 (Si<sup>1,4</sup>); UV (cyclohexane) λ<sub>max</sub> 280 nm (sh) (ε 7600 mol<sup>-1</sup>dm<sup>3</sup>cm<sup>-1</sup>); MS m/e (relative intensity) 908 (7, M<sup>+</sup>), 837 (3, [M-CH<sub>2</sub>Bu<sup>t</sup>]<sup>+</sup>), 667(4), 136(100). Anal. Calcd for C<sub>52</sub>H<sub>98</sub>Si<sub>4</sub>Ge: C, 68.76; H, 10.88%. Found: C, 67.93; H, 10.98%.
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- 7 Selected bond distances (Å) and angles (°), and torsion angles (°) for 1b: Ge(1)-Si(1) 2.443(3), Si(1)-Si(2) 2.402(3), Si(2)-Si(3) 2.416(3), Si(3)-Si(4) 2.424(4), Si(4)-Ge(1) 2.455(3); Si(1)-Ge(1)-Si(4) 109.7(1), Ge(1)-Si(1)-Si(2) 101.0(1), Si(1)-Si(2)-Si(3) 101.4(1), Si(2)-Si(3)-Si(4) 103.1(1), Si(1)-Si(4)-Ge(1) 99.6(1); Si(2)-Si(1)-Ge(1)-Si(4) 16.2(1), Si(2)-Si(3)-Si(4)-Ge(1) -39.3(1), Si(3)-Si(4)-Ge(1)-Si(1) 14.1(1), Si(1)-Si(2)-Si(3)-Si(4) 51.7(1), Ge(1)-Si(1)-Si(2)-Si(3) -40.2(1).
- 8 Crystal data for 1a: C<sub>36</sub>H<sub>66</sub>Si<sub>4</sub>Ge; fw 683.861; monoclinic; space group P2<sub>1</sub>/a; a = 11.595(5), b = 20.013(5), c = 17.386(5) Å; β = 101.06(2)°; V = 3960(2) Å<sup>3</sup>; Z = 4; D<sub>c</sub> = 1.147 g cm<sup>-3</sup>; μ (Cu-Kα) = 24.0 cm<sup>-1</sup>. R(Rw) = 0.0434(0.0563).
- 9 Crystal data for 1b: C<sub>52</sub>H<sub>98</sub>Si<sub>4</sub>Ge; fw 908.259; monoclinic; space group P2<sub>1</sub>/a; a = 19.943(4), b = 15.428(1), c = 21.543(4) Å; β = 105.59(1)°; V = 6384.5(2) Å<sup>3</sup>; Z = 4; D<sub>c</sub> = 0.9447 g cm<sup>-3</sup>; μ (Cu-Kα) = 15.8 cm<sup>-1</sup>. R(Rw) = 0.0887(0.0897).
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